

Global Sputtering Target Material for Semiconductor Market Research Report 2023

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Abstracts

Sputtering is the process of forming a thin film when the object is attached to the target substrate by the sputtering and scattering, and the sputtering target is the material for high-speed particle bombardment. This report studies the sputtering target material market.

According to QYResearch's new survey, global Sputtering Target Material for Semiconductor market is projected to reach US\$ 1857.3 million in 2029, increasing from US\$ 1453.8 million in 2022, with the CAGR of 3.8% during the period of 2023 to 2029. Influencing issues, such as economy environments, COVID-19 and Russia-Ukraine War, have led to great market fluctuations in the past few years and are considered comprehensively in the whole Sputtering Target Material for Semiconductor market research.

Following a strong growth of 26.2 percent in the year 2021, WSTS revised it down to a single digit growth for the worldwide semiconductor market in 2022 with a total size of US\$580 billion, up 4.4 percent. WSTS lowered growth estimation as inflation rises and end markets seeing weaker demand, especially those exposed to consumer spending. While some major categories are still double-digit year-over-year growth in 2022, led by Analog with 20.8 percent, Sensors with 16.3 percent, and Logic with 14.5 percent growth. Memory declined with 12.6 percent year over year. In 2022, all geographical regions showed double-digit growth except Asia Pacific. The largest region, Asia Pacific, declined 2.0 percent. Sales in the Americas were US\$142.1 billion, up 17.0% year-on-year, sales in Europe were US\$53.8 billion, up 12.6% year-on-year, and sales in Japan were US\$48.1 billion, up 10.0% year-on-year. However, sales in the largest Asia-Pacific region were US\$336.2 billion, down 2.0% year-on-year.



Report Scope

This report, based on historical analysis (2018-2022) and forecast calculation (2023-2029), aims to help readers to get a comprehensive understanding of global Sputtering Target Material for Semiconductor market with multiple angles, which provides sufficient supports to readers' strategy and decision making.

By Company JX Nippon Mining & Metals Corporation Praxair Plansee SE Mitsui Mining & Smelting Hitachi Metals Honeywell Sumitomo Chemical **ULVAC** Materion (Heraeus) GRIKIN Advanced Material Co., Ltd. TOSOH Ningbo Jiangfeng Heesung Luvata Fujian Acetron New Materials Co., Ltd



(Changzhou Sujing Electronic Material
L	uoyang Sifon Electronic Materials
F	FURAYA Metals Co., Ltd
A	Advantec
A	Angstrom Sciences
l	Jmicore Thin Film Products
7	ΓΑΝΑΚΑ
C a avec a ra	A bu Turo o
Segment by Type	
N	Metal Sputtering Target Material
A	Alloy Sputtering Target Material
Segment by Application	
A	Analog IC
[Digital IC
A	Analog/Digital IC
Production by Region	
١	North America
E	Europe
(China



Japan	
Consumption I	by Region
North A	America
	U.S.
	Canada
Europe	e
	Germany
	France
	U.K.
	Italy
	Russia
Asia-P	acific
	China
	Japan
	South Korea
	China Taiwan
	Southeast Asia
	India

Latin America, Middle East & Africa



Mexico		
Brazil		
Turkey		
GCC Countries		
The Sputtering Target Material for Semiconductor report covers below items:		
Chapter 1: Product Basic Information (Definition, type and application)		
Chapter 2: Manufacturers' Competition Patterns		
Chapter 3: Production Region Distribution and Analysis		
Chapter 4: Country Level Sales Analysis		
Chapter 5: Product Type Analysis		
Chapter 6: Product Application Analysis		
Chapter 7: Manufacturers' Outline		
Chapter 8: Industry Chain, Market Channel and Customer Analysis		
Chapter 9: Market Opportunities and Challenges		
Chapter 10: Market Conclusions		
Chapter 11: Research Methodology and Data Source		



Contents

1 SPUTTERING TARGET MATERIAL FOR SEMICONDUCTOR MARKET OVERVIEW

- 1.1 Product Definition
- 1.2 Sputtering Target Material for Semiconductor Segment by Type
- 1.2.1 Global Sputtering Target Material for Semiconductor Market Value Growth Rate Analysis by Type 2022 VS 2029
 - 1.2.2 Metal Sputtering Target Material
 - 1.2.3 Alloy Sputtering Target Material
- 1.3 Sputtering Target Material for Semiconductor Segment by Application
- 1.3.1 Global Sputtering Target Material for Semiconductor Market Value Growth Rate Analysis by Application: 2022 VS 2029
 - 1.3.2 Analog IC
 - 1.3.3 Digital IC
 - 1.3.4 Analog/Digital IC
- 1.4 Global Market Growth Prospects
- 1.4.1 Global Sputtering Target Material for Semiconductor Production Value Estimates and Forecasts (2018-2029)
- 1.4.2 Global Sputtering Target Material for Semiconductor Production Capacity Estimates and Forecasts (2018-2029)
- 1.4.3 Global Sputtering Target Material for Semiconductor Production Estimates and Forecasts (2018-2029)
- 1.4.4 Global Sputtering Target Material for Semiconductor Market Average Price Estimates and Forecasts (2018-2029)
- 1.5 Assumptions and Limitations

2 MARKET COMPETITION BY MANUFACTURERS

- 2.1 Global Sputtering Target Material for Semiconductor Production Market Share by Manufacturers (2018-2023)
- 2.2 Global Sputtering Target Material for Semiconductor Production Value Market Share by Manufacturers (2018-2023)
- 2.3 Global Key Players of Sputtering Target Material for Semiconductor, Industry Ranking, 2021 VS 2022 VS 2023
- 2.4 Global Sputtering Target Material for Semiconductor Market Share by Company Type (Tier 1, Tier 2 and Tier 3)
- 2.5 Global Sputtering Target Material for Semiconductor Average Price by Manufacturers (2018-2023)



- 2.6 Global Key Manufacturers of Sputtering Target Material for Semiconductor, Manufacturing Base Distribution and Headquarters
- 2.7 Global Key Manufacturers of Sputtering Target Material for Semiconductor, Product Offered and Application
- 2.8 Global Key Manufacturers of Sputtering Target Material for Semiconductor, Date of Enter into This Industry
- 2.9 Sputtering Target Material for Semiconductor Market Competitive Situation and Trends
 - 2.9.1 Sputtering Target Material for Semiconductor Market Concentration Rate
- 2.9.2 Global 5 and 10 Largest Sputtering Target Material for Semiconductor Players Market Share by Revenue
- 2.10 Mergers & Acquisitions, Expansion

3 SPUTTERING TARGET MATERIAL FOR SEMICONDUCTOR PRODUCTION BY REGION

- 3.1 Global Sputtering Target Material for Semiconductor Production Value Estimates and Forecasts by Region: 2018 VS 2022 VS 2029
- 3.2 Global Sputtering Target Material for Semiconductor Production Value by Region (2018-2029)
- 3.2.1 Global Sputtering Target Material for Semiconductor Production Value Market Share by Region (2018-2023)
- 3.2.2 Global Forecasted Production Value of Sputtering Target Material for Semiconductor by Region (2024-2029)
- 3.3 Global Sputtering Target Material for Semiconductor Production Estimates and Forecasts by Region: 2018 VS 2022 VS 2029
- 3.4 Global Sputtering Target Material for Semiconductor Production by Region (2018-2029)
- 3.4.1 Global Sputtering Target Material for Semiconductor Production Market Share by Region (2018-2023)
- 3.4.2 Global Forecasted Production of Sputtering Target Material for Semiconductor by Region (2024-2029)
- 3.5 Global Sputtering Target Material for Semiconductor Market Price Analysis by Region (2018-2023)
- 3.6 Global Sputtering Target Material for Semiconductor Production and Value, Year-over-Year Growth
- 3.6.1 North America Sputtering Target Material for Semiconductor Production Value Estimates and Forecasts (2018-2029)
 - 3.6.2 Europe Sputtering Target Material for Semiconductor Production Value



Estimates and Forecasts (2018-2029)

- 3.6.3 China Sputtering Target Material for Semiconductor Production Value Estimates and Forecasts (2018-2029)
- 3.6.4 Japan Sputtering Target Material for Semiconductor Production Value Estimates and Forecasts (2018-2029)

4 SPUTTERING TARGET MATERIAL FOR SEMICONDUCTOR CONSUMPTION BY REGION

- 4.1 Global Sputtering Target Material for Semiconductor Consumption Estimates and Forecasts by Region: 2018 VS 2022 VS 2029
- 4.2 Global Sputtering Target Material for Semiconductor Consumption by Region (2018-2029)
- 4.2.1 Global Sputtering Target Material for Semiconductor Consumption by Region (2018-2023)
- 4.2.2 Global Sputtering Target Material for Semiconductor Forecasted Consumption by Region (2024-2029)
- 4.3 North America
- 4.3.1 North America Sputtering Target Material for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029
- 4.3.2 North America Sputtering Target Material for Semiconductor Consumption by Country (2018-2029)
 - 4.3.3 U.S.
 - 4.3.4 Canada
- 4.4 Europe
- 4.4.1 Europe Sputtering Target Material for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029
- 4.4.2 Europe Sputtering Target Material for Semiconductor Consumption by Country (2018-2029)
- 4.4.3 Germany
- 4.4.4 France
- 4.4.5 U.K.
- 4.4.6 Italy
- 4.4.7 Russia
- 4.5 Asia Pacific
- 4.5.1 Asia Pacific Sputtering Target Material for Semiconductor Consumption Growth Rate by Region: 2018 VS 2022 VS 2029
- 4.5.2 Asia Pacific Sputtering Target Material for Semiconductor Consumption by Region (2018-2029)



- 4.5.3 China
- 4.5.4 Japan
- 4.5.5 South Korea
- 4.5.6 China Taiwan
- 4.5.7 Southeast Asia
- 4.5.8 India
- 4.6 Latin America, Middle East & Africa
- 4.6.1 Latin America, Middle East & Africa Sputtering Target Material for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029
- 4.6.2 Latin America, Middle East & Africa Sputtering Target Material for Semiconductor Consumption by Country (2018-2029)
 - 4.6.3 Mexico
 - 4.6.4 Brazil
 - 4.6.5 Turkey

5 SEGMENT BY TYPE

- 5.1 Global Sputtering Target Material for Semiconductor Production by Type (2018-2029)
- 5.1.1 Global Sputtering Target Material for Semiconductor Production by Type
 (2018-2023)
- 5.1.2 Global Sputtering Target Material for Semiconductor Production by Type (2024-2029)
- 5.1.3 Global Sputtering Target Material for Semiconductor Production Market Share by Type (2018-2029)
- 5.2 Global Sputtering Target Material for Semiconductor Production Value by Type (2018-2029)
- 5.2.1 Global Sputtering Target Material for Semiconductor Production Value by Type (2018-2023)
- 5.2.2 Global Sputtering Target Material for Semiconductor Production Value by Type (2024-2029)
- 5.2.3 Global Sputtering Target Material for Semiconductor Production Value Market Share by Type (2018-2029)
- 5.3 Global Sputtering Target Material for Semiconductor Price by Type (2018-2029)

6 SEGMENT BY APPLICATION

6.1 Global Sputtering Target Material for Semiconductor Production by Application (2018-2029)



- 6.1.1 Global Sputtering Target Material for Semiconductor Production by Application (2018-2023)
- 6.1.2 Global Sputtering Target Material for Semiconductor Production by Application (2024-2029)
- 6.1.3 Global Sputtering Target Material for Semiconductor Production Market Share by Application (2018-2029)
- 6.2 Global Sputtering Target Material for Semiconductor Production Value by Application (2018-2029)
- 6.2.1 Global Sputtering Target Material for Semiconductor Production Value by Application (2018-2023)
- 6.2.2 Global Sputtering Target Material for Semiconductor Production Value by Application (2024-2029)
- 6.2.3 Global Sputtering Target Material for Semiconductor Production Value Market Share by Application (2018-2029)
- 6.3 Global Sputtering Target Material for Semiconductor Price by Application (2018-2029)

7 KEY COMPANIES PROFILED

- 7.1 JX Nippon Mining & Metals Corporation
- 7.1.1 JX Nippon Mining & Metals Corporation Sputtering Target Material for Semiconductor Corporation Information
- 7.1.2 JX Nippon Mining & Metals Corporation Sputtering Target Material for Semiconductor Product Portfolio
- 7.1.3 JX Nippon Mining & Metals Corporation Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.1.4 JX Nippon Mining & Metals Corporation Main Business and Markets Served
- 7.1.5 JX Nippon Mining & Metals Corporation Recent Developments/Updates 7.2 Praxair
- 7.2.1 Praxair Sputtering Target Material for Semiconductor Corporation Information
- 7.2.2 Praxair Sputtering Target Material for Semiconductor Product Portfolio
- 7.2.3 Praxair Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.2.4 Praxair Main Business and Markets Served
 - 7.2.5 Praxair Recent Developments/Updates
- 7.3 Plansee SE
- 7.3.1 Plansee SE Sputtering Target Material for Semiconductor Corporation Information
- 7.3.2 Plansee SE Sputtering Target Material for Semiconductor Product Portfolio



- 7.3.3 Plansee SE Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.3.4 Plansee SE Main Business and Markets Served
 - 7.3.5 Plansee SE Recent Developments/Updates
- 7.4 Mitsui Mining & Smelting
- 7.4.1 Mitsui Mining & Smelting Sputtering Target Material for Semiconductor Corporation Information
- 7.4.2 Mitsui Mining & Smelting Sputtering Target Material for Semiconductor Product Portfolio
- 7.4.3 Mitsui Mining & Smelting Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
- 7.4.4 Mitsui Mining & Smelting Main Business and Markets Served
- 7.4.5 Mitsui Mining & Smelting Recent Developments/Updates
- 7.5 Hitachi Metals
- 7.5.1 Hitachi Metals Sputtering Target Material for Semiconductor Corporation Information
 - 7.5.2 Hitachi Metals Sputtering Target Material for Semiconductor Product Portfolio
- 7.5.3 Hitachi Metals Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
- 7.5.4 Hitachi Metals Main Business and Markets Served
- 7.5.5 Hitachi Metals Recent Developments/Updates
- 7.6 Honeywell
 - 7.6.1 Honeywell Sputtering Target Material for Semiconductor Corporation Information
 - 7.6.2 Honeywell Sputtering Target Material for Semiconductor Product Portfolio
- 7.6.3 Honeywell Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.6.4 Honeywell Main Business and Markets Served
 - 7.6.5 Honeywell Recent Developments/Updates
- 7.7 Sumitomo Chemical
- 7.7.1 Sumitomo Chemical Sputtering Target Material for Semiconductor Corporation Information
- 7.7.2 Sumitomo Chemical Sputtering Target Material for Semiconductor Product Portfolio
- 7.7.3 Sumitomo Chemical Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.7.4 Sumitomo Chemical Main Business and Markets Served
 - 7.7.5 Sumitomo Chemical Recent Developments/Updates
- 7.8 ULVAC
 - 7.8.1 ULVAC Sputtering Target Material for Semiconductor Corporation Information



- 7.8.2 ULVAC Sputtering Target Material for Semiconductor Product Portfolio
- 7.8.3 ULVAC Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.8.4 ULVAC Main Business and Markets Served
- 7.7.5 ULVAC Recent Developments/Updates
- 7.9 Materion (Heraeus)
- 7.9.1 Materion (Heraeus) Sputtering Target Material for Semiconductor Corporation Information
- 7.9.2 Materion (Heraeus) Sputtering Target Material for Semiconductor Product Portfolio
- 7.9.3 Materion (Heraeus) Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.9.4 Materion (Heraeus) Main Business and Markets Served
- 7.9.5 Materion (Heraeus) Recent Developments/Updates
- 7.10 GRIKIN Advanced Material Co., Ltd.
- 7.10.1 GRIKIN Advanced Material Co., Ltd. Sputtering Target Material for Semiconductor Corporation Information
- 7.10.2 GRIKIN Advanced Material Co., Ltd. Sputtering Target Material for Semiconductor Product Portfolio
- 7.10.3 GRIKIN Advanced Material Co., Ltd. Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
- 7.10.4 GRIKIN Advanced Material Co., Ltd. Main Business and Markets Served
- 7.10.5 GRIKIN Advanced Material Co., Ltd. Recent Developments/Updates
- **7.11 TOSOH**
 - 7.11.1 TOSOH Sputtering Target Material for Semiconductor Corporation Information
 - 7.11.2 TOSOH Sputtering Target Material for Semiconductor Product Portfolio
- 7.11.3 TOSOH Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.11.4 TOSOH Main Business and Markets Served
 - 7.11.5 TOSOH Recent Developments/Updates
- 7.12 Ningbo Jiangfeng
- 7.12.1 Ningbo Jiangfeng Sputtering Target Material for Semiconductor Corporation Information
- 7.12.2 Ningbo Jiangfeng Sputtering Target Material for Semiconductor Product Portfolio
- 7.12.3 Ningbo Jiangfeng Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.12.4 Ningbo Jiangfeng Main Business and Markets Served
 - 7.12.5 Ningbo Jiangfeng Recent Developments/Updates



7.13 Heesung

- 7.13.1 Heesung Sputtering Target Material for Semiconductor Corporation Information
- 7.13.2 Heesung Sputtering Target Material for Semiconductor Product Portfolio
- 7.13.3 Heesung Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.13.4 Heesung Main Business and Markets Served
 - 7.13.5 Heesung Recent Developments/Updates

7.14 Luvata

- 7.14.1 Luvata Sputtering Target Material for Semiconductor Corporation Information
- 7.14.2 Luvata Sputtering Target Material for Semiconductor Product Portfolio
- 7.14.3 Luvata Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.14.4 Luvata Main Business and Markets Served
 - 7.14.5 Luvata Recent Developments/Updates
- 7.15 Fujian Acetron New Materials Co., Ltd
- 7.15.1 Fujian Acetron New Materials Co., Ltd Sputtering Target Material for Semiconductor Corporation Information
- 7.15.2 Fujian Acetron New Materials Co., Ltd Sputtering Target Material for Semiconductor Product Portfolio
- 7.15.3 Fujian Acetron New Materials Co., Ltd Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
- 7.15.4 Fujian Acetron New Materials Co., Ltd Main Business and Markets Served
- 7.15.5 Fujian Acetron New Materials Co., Ltd Recent Developments/Updates
- 7.16 Changzhou Sujing Electronic Material
- 7.16.1 Changzhou Sujing Electronic Material Sputtering Target Material for Semiconductor Corporation Information
- 7.16.2 Changzhou Sujing Electronic Material Sputtering Target Material for Semiconductor Product Portfolio
- 7.16.3 Changzhou Sujing Electronic Material Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.16.4 Changzhou Sujing Electronic Material Main Business and Markets Served
- 7.16.5 Changzhou Sujing Electronic Material Recent Developments/Updates
- 7.17 Luoyang Sifon Electronic Materials
- 7.17.1 Luoyang Sifon Electronic Materials Sputtering Target Material for Semiconductor Corporation Information
- 7.17.2 Luoyang Sifon Electronic Materials Sputtering Target Material for Semiconductor Product Portfolio
- 7.17.3 Luoyang Sifon Electronic Materials Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)



- 7.17.4 Luoyang Sifon Electronic Materials Main Business and Markets Served
- 7.17.5 Luoyang Sifon Electronic Materials Recent Developments/Updates
- 7.18 FURAYA Metals Co., Ltd
- 7.18.1 FURAYA Metals Co., Ltd Sputtering Target Material for Semiconductor Corporation Information
- 7.18.2 FURAYA Metals Co., Ltd Sputtering Target Material for Semiconductor Product Portfolio
- 7.18.3 FURAYA Metals Co., Ltd Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
- 7.18.4 FURAYA Metals Co., Ltd Main Business and Markets Served
- 7.18.5 FURAYA Metals Co., Ltd Recent Developments/Updates
- 7.19 Advantec
 - 7.19.1 Advantec Sputtering Target Material for Semiconductor Corporation Information
 - 7.19.2 Advantec Sputtering Target Material for Semiconductor Product Portfolio
- 7.19.3 Advantec Sputtering Target Material for Semiconductor Production, Value,
- Price and Gross Margin (2018-2023)
 - 7.19.4 Advantec Main Business and Markets Served
- 7.19.5 Advantec Recent Developments/Updates
- 7.20 Angstrom Sciences
- 7.20.1 Angstrom Sciences Sputtering Target Material for Semiconductor Corporation Information
- 7.20.2 Angstrom Sciences Sputtering Target Material for Semiconductor Product Portfolio
- 7.20.3 Angstrom Sciences Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.20.4 Angstrom Sciences Main Business and Markets Served
 - 7.20.5 Angstrom Sciences Recent Developments/Updates
- 7.21 Umicore Thin Film Products
- 7.21.1 Umicore Thin Film Products Sputtering Target Material for Semiconductor Corporation Information
- 7.21.2 Umicore Thin Film Products Sputtering Target Material for Semiconductor Product Portfolio
- 7.21.3 Umicore Thin Film Products Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
- 7.21.4 Umicore Thin Film Products Main Business and Markets Served
- 7.21.5 Umicore Thin Film Products Recent Developments/Updates
- 7.22 TANAKA
- 7.22.1 TANAKA Sputtering Target Material for Semiconductor Corporation Information
- 7.22.2 TANAKA Sputtering Target Material for Semiconductor Product Portfolio



- 7.22.3 TANAKA Sputtering Target Material for Semiconductor Production, Value, Price and Gross Margin (2018-2023)
 - 7.22.4 TANAKA Main Business and Markets Served
 - 7.22.5 TANAKA Recent Developments/Updates

8 INDUSTRY CHAIN AND SALES CHANNELS ANALYSIS

- 8.1 Sputtering Target Material for Semiconductor Industry Chain Analysis
- 8.2 Sputtering Target Material for Semiconductor Key Raw Materials
 - 8.2.1 Key Raw Materials
 - 8.2.2 Raw Materials Key Suppliers
- 8.3 Sputtering Target Material for Semiconductor Production Mode & Process
- 8.4 Sputtering Target Material for Semiconductor Sales and Marketing
 - 8.4.1 Sputtering Target Material for Semiconductor Sales Channels
 - 8.4.2 Sputtering Target Material for Semiconductor Distributors
- 8.5 Sputtering Target Material for Semiconductor Customers

9 SPUTTERING TARGET MATERIAL FOR SEMICONDUCTOR MARKET DYNAMICS

- 9.1 Sputtering Target Material for Semiconductor Industry Trends
- 9.2 Sputtering Target Material for Semiconductor Market Drivers
- 9.3 Sputtering Target Material for Semiconductor Market Challenges
- 9.4 Sputtering Target Material for Semiconductor Market Restraints

10 RESEARCH FINDING AND CONCLUSION

11 METHODOLOGY AND DATA SOURCE

- 11.1 Methodology/Research Approach
- 11.1.1 Research Programs/Design
- 11.1.2 Market Size Estimation
- 11.1.3 Market Breakdown and Data Triangulation
- 11.2 Data Source
 - 11.2.1 Secondary Sources
 - 11.2.2 Primary Sources
- 11.3 Author List
- 11.4 Disclaimer



List Of Tables

LIST OF TABLES

Table 1. Global Sputtering Target Material for Semiconductor Market Value by Type, (US\$ Million) & (2022 VS 2029)

Table 2. Global Sputtering Target Material for Semiconductor Market Value by Application, (US\$ Million) & (2022 VS 2029)

Table 3. Global Sputtering Target Material for Semiconductor Production Capacity (MT) by Manufacturers in 2022

Table 4. Global Sputtering Target Material for Semiconductor Production by Manufacturers (2018-2023) & (MT)

Table 5. Global Sputtering Target Material for Semiconductor Production Market Share by Manufacturers (2018-2023)

Table 6. Global Sputtering Target Material for Semiconductor Production Value by Manufacturers (2018-2023) & (US\$ Million)

Table 7. Global Sputtering Target Material for Semiconductor Production Value Share by Manufacturers (2018-2023)

Table 8. Global Sputtering Target Material for Semiconductor Industry Ranking 2021 VS 2022 VS 2023

Table 9. Company Type (Tier 1, Tier 2 and Tier 3) & (based on the Revenue in Sputtering Target Material for Semiconductor as of 2022)

Table 10. Global Market Sputtering Target Material for Semiconductor Average Price by Manufacturers (USD/Kg) & (2018-2023)

Table 11. Manufacturers Sputtering Target Material for Semiconductor Production Sites and Area Served

Table 12. Manufacturers Sputtering Target Material for Semiconductor Product Types

Table 13. Global Sputtering Target Material for Semiconductor Manufacturers Market Concentration Ratio (CR5 and HHI)

Table 14. Mergers & Acquisitions, Expansion

Table 15. Global Sputtering Target Material for Semiconductor Production Value by Region: 2018 VS 2022 VS 2029 (US\$ Million)

Table 16. Global Sputtering Target Material for Semiconductor Production Value (US\$ Million) by Region (2018-2023)

Table 17. Global Sputtering Target Material for Semiconductor Production Value Market Share by Region (2018-2023)

Table 18. Global Sputtering Target Material for Semiconductor Production Value (US\$ Million) Forecast by Region (2024-2029)

Table 19. Global Sputtering Target Material for Semiconductor Production Value Market



Share Forecast by Region (2024-2029)

Table 20. Global Sputtering Target Material for Semiconductor Production Comparison by Region: 2018 VS 2022 VS 2029 (MT)

Table 21. Global Sputtering Target Material for Semiconductor Production (MT) by Region (2018-2023)

Table 22. Global Sputtering Target Material for Semiconductor Production Market Share by Region (2018-2023)

Table 23. Global Sputtering Target Material for Semiconductor Production (MT) Forecast by Region (2024-2029)

Table 24. Global Sputtering Target Material for Semiconductor Production Market Share Forecast by Region (2024-2029)

Table 25. Global Sputtering Target Material for Semiconductor Market Average Price (USD/Kg) by Region (2018-2023)

Table 26. Global Sputtering Target Material for Semiconductor Market Average Price (USD/Kg) by Region (2024-2029)

Table 27. Global Sputtering Target Material for Semiconductor Consumption Growth Rate by Region: 2018 VS 2022 VS 2029 (MT)

Table 28. Global Sputtering Target Material for Semiconductor Consumption by Region (2018-2023) & (MT)

Table 29. Global Sputtering Target Material for Semiconductor Consumption Market Share by Region (2018-2023)

Table 30. Global Sputtering Target Material for Semiconductor Forecasted Consumption by Region (2024-2029) & (MT)

Table 31. Global Sputtering Target Material for Semiconductor Forecasted Consumption Market Share by Region (2018-2023)

Table 32. North America Sputtering Target Material for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029 (MT)

Table 33. North America Sputtering Target Material for Semiconductor Consumption by Country (2018-2023) & (MT)

Table 34. North America Sputtering Target Material for Semiconductor Consumption by Country (2024-2029) & (MT)

Table 35. Europe Sputtering Target Material for Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029 (MT)

Table 36. Europe Sputtering Target Material for Semiconductor Consumption by Country (2018-2023) & (MT)

Table 37. Europe Sputtering Target Material for Semiconductor Consumption by Country (2024-2029) & (MT)

Table 38. Asia Pacific Sputtering Target Material for Semiconductor Consumption Growth Rate by Region: 2018 VS 2022 VS 2029 (MT)



Table 39. Asia Pacific Sputtering Target Material for Semiconductor Consumption by Region (2018-2023) & (MT)

Table 40. Asia Pacific Sputtering Target Material for Semiconductor Consumption by Region (2024-2029) & (MT)

Table 41. Latin America, Middle East & Africa Sputtering Target Material for

Semiconductor Consumption Growth Rate by Country: 2018 VS 2022 VS 2029 (MT)

Table 42. Latin America, Middle East & Africa Sputtering Target Material for

Semiconductor Consumption by Country (2018-2023) & (MT)

Table 43. Latin America, Middle East & Africa Sputtering Target Material for Semiconductor Consumption by Country (2024-2029) & (MT)

Table 44. Global Sputtering Target Material for Semiconductor Production (MT) by Type (2018-2023)

Table 45. Global Sputtering Target Material for Semiconductor Production (MT) by Type (2024-2029)

Table 46. Global Sputtering Target Material for Semiconductor Production Market Share by Type (2018-2023)

Table 47. Global Sputtering Target Material for Semiconductor Production Market Share by Type (2024-2029)

Table 48. Global Sputtering Target Material for Semiconductor Production Value (US\$ Million) by Type (2018-2023)

Table 49. Global Sputtering Target Material for Semiconductor Production Value (US\$ Million) by Type (2024-2029)

Table 50. Global Sputtering Target Material for Semiconductor Production Value Share by Type (2018-2023)

Table 51. Global Sputtering Target Material for Semiconductor Production Value Share by Type (2024-2029)

Table 52. Global Sputtering Target Material for Semiconductor Price (USD/Kg) by Type (2018-2023)

Table 53. Global Sputtering Target Material for Semiconductor Price (USD/Kg) by Type (2024-2029)

Table 54. Global Sputtering Target Material for Semiconductor Production (MT) by Application (2018-2023)

Table 55. Global Sputtering Target Material for Semiconductor Production (MT) by Application (2024-2029)

Table 56. Global Sputtering Target Material for Semiconductor Production Market Share by Application (2018-2023)

Table 57. Global Sputtering Target Material for Semiconductor Production Market Share by Application (2024-2029)

Table 58. Global Sputtering Target Material for Semiconductor Production Value (US\$



Million) by Application (2018-2023)

Table 59. Global Sputtering Target Material for Semiconductor Production Value (US\$ Million) by Application (2024-2029)

Table 60. Global Sputtering Target Material for Semiconductor Production Value Share by Application (2018-2023)

Table 61. Global Sputtering Target Material for Semiconductor Production Value Share by Application (2024-2029)

Table 62. Global Sputtering Target Material for Semiconductor Price (USD/Kg) by Application (2018-2023)

Table 63. Global Sputtering Target Material for Semiconductor Price (USD/Kg) by Application (2024-2029)

Table 64. JX Nippon Mining & Metals Corporation Sputtering Target Material for Semiconductor Corporation Information

Table 65. JX Nippon Mining & Metals Corporation Specification and Application

Table 66. JX Nippon Mining & Metals Corporation Sputtering Target Material for Semiconductor Production (MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 67. JX Nippon Mining & Metals Corporation Main Business and Markets Served

Table 68. JX Nippon Mining & Metals Corporation Recent Developments/Updates

Table 69. Praxair Sputtering Target Material for Semiconductor Corporation Information

Table 70. Praxair Specification and Application

Table 71. Praxair Sputtering Target Material for Semiconductor Production (MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 72. Praxair Main Business and Markets Served

Table 73. Praxair Recent Developments/Updates

Table 74. Plansee SE Sputtering Target Material for Semiconductor Corporation Information

Table 75. Plansee SE Specification and Application

Table 76. Plansee SE Sputtering Target Material for Semiconductor Production (MT),

Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 77. Plansee SE Main Business and Markets Served

Table 78. Plansee SE Recent Developments/Updates

Table 79. Mitsui Mining & Smelting Sputtering Target Material for Semiconductor Corporation Information

Table 80. Mitsui Mining & Smelting Specification and Application

Table 81. Mitsui Mining & Smelting Sputtering Target Material for Semiconductor

Production (MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 82. Mitsui Mining & Smelting Main Business and Markets Served

Table 83. Mitsui Mining & Smelting Recent Developments/Updates



Table 84. Hitachi Metals Sputtering Target Material for Semiconductor Corporation Information

Table 85. Hitachi Metals Specification and Application

Table 86. Hitachi Metals Sputtering Target Material for Semiconductor Production (MT),

Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 87. Hitachi Metals Main Business and Markets Served

Table 88. Hitachi Metals Recent Developments/Updates

Table 89. Honeywell Sputtering Target Material for Semiconductor Corporation Information

Table 90. Honeywell Specification and Application

Table 91. Honeywell Sputtering Target Material for Semiconductor Production (MT),

Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 92. Honeywell Main Business and Markets Served

Table 93. Honeywell Recent Developments/Updates

Table 94. Sumitomo Chemical Sputtering Target Material for Semiconductor

Corporation Information

Table 95. Sumitomo Chemical Specification and Application

Table 96. Sumitomo Chemical Sputtering Target Material for Semiconductor Production

(MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 97. Sumitomo Chemical Main Business and Markets Served

Table 98. Sumitomo Chemical Recent Developments/Updates

Table 99. ULVAC Sputtering Target Material for Semiconductor Corporation Information

Table 100. ULVAC Specification and Application

Table 101. ULVAC Sputtering Target Material for Semiconductor Production (MT),

Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 102. ULVAC Main Business and Markets Served

Table 103. ULVAC Recent Developments/Updates

Table 104. Materion (Heraeus) Sputtering Target Material for Semiconductor

Corporation Information

Table 105. Materion (Heraeus) Specification and Application

Table 106. Materion (Heraeus) Sputtering Target Material for Semiconductor Production

(MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 107. Materion (Heraeus) Main Business and Markets Served

Table 108. Materion (Heraeus) Recent Developments/Updates

Table 109. GRIKIN Advanced Material Co., Ltd. Sputtering Target Material for

Semiconductor Corporation Information

Table 110. GRIKIN Advanced Material Co., Ltd. Specification and Application

Table 111. GRIKIN Advanced Material Co., Ltd. Sputtering Target Material for

Semiconductor Production (MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin



(2018-2023)

- Table 112. GRIKIN Advanced Material Co., Ltd. Main Business and Markets Served
- Table 113. GRIKIN Advanced Material Co., Ltd. Recent Developments/Updates
- Table 114. TOSOH Sputtering Target Material for Semiconductor Corporation Information
- Table 115. TOSOH Specification and Application
- Table 116. TOSOH Sputtering Target Material for Semiconductor Production (MT),
- Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)
- Table 117. TOSOH Main Business and Markets Served
- Table 118. TOSOH Recent Developments/Updates
- Table 119. Ningbo Jiangfeng Sputtering Target Material for Semiconductor Corporation Information
- Table 120. Ningbo Jiangfeng Specification and Application
- Table 121. Ningbo Jiangfeng Sputtering Target Material for Semiconductor Production
- (MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)
- Table 122. Ningbo Jiangfeng Main Business and Markets Served
- Table 123. Ningbo Jiangfeng Recent Developments/Updates
- Table 124. Heesung Sputtering Target Material for Semiconductor Corporation Information
- Table 125. Heesung Specification and Application
- Table 126. Heesung Sputtering Target Material for Semiconductor Production (MT),
- Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)
- Table 127. Heesung Main Business and Markets Served
- Table 128. Heesung Recent Developments/Updates
- Table 129. Luvata Sputtering Target Material for Semiconductor Corporation Information
- Table 130. Luvata Specification and Application
- Table 131. Luvata Sputtering Target Material for Semiconductor Production (MT), Value
- (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)
- Table 132. Luvata Main Business and Markets Served
- Table 133. Luvata Recent Developments/Updates
- Table 134. Luvata Sputtering Target Material for Semiconductor Corporation Information
- Table 135. Fujian Acetron New Materials Co., Ltd Specification and Application
- Table 136. Fujian Acetron New Materials Co., Ltd Sputtering Target Material for
- Semiconductor Production (MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)
- Table 137. Fujian Acetron New Materials Co., Ltd Main Business and Markets Served
- Table 138. Fujian Acetron New Materials Co., Ltd Recent Developments/Updates



Table 139. Changzhou Sujing Electronic Material Sputtering Target Material for Semiconductor Corporation Information

Table 140. Changzhou Sujing Electronic Material Sputtering Target Material for Semiconductor Production (MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 141. Changzhou Sujing Electronic Material Main Business and Markets Served

Table 142. Changzhou Sujing Electronic Material Recent Developments/Updates

Table 143. Luoyang Sifon Electronic Materials Sputtering Target Material for Semiconductor Corporation Information

Table 144. Luoyang Sifon Electronic Materials Specification and Application

Table 145. Luoyang Sifon Electronic Materials Sputtering Target Material for Semiconductor Production (MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 146. Luoyang Sifon Electronic Materials Main Business and Markets Served

Table 147. Luoyang Sifon Electronic Materials Recent Developments/Updates

Table 148. FURAYA Metals Co., Ltd Sputtering Target Material for Semiconductor Corporation Information

Table 149. FURAYA Metals Co., Ltd Specification and Application

Table 150. FURAYA Metals Co., Ltd Sputtering Target Material for Semiconductor

Production (MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 151. FURAYA Metals Co., Ltd Main Business and Markets Served

Table 152. FURAYA Metals Co., Ltd Recent Developments/Updates

Table 153. Advantec Sputtering Target Material for Semiconductor Corporation Information

Table 154. Advantec Specification and Application

Table 155. Advantec Sputtering Target Material for Semiconductor Production (MT),

Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 156. Advantec Main Business and Markets Served

Table 157. Advantec Recent Developments/Updates

Table 158. Angstrom Sciences Sputtering Target Material for Semiconductor Corporation Information

Table 159. Angstrom Sciences Specification and Application

Table 160. Angstrom Sciences Sputtering Target Material for Semiconductor Production

(MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 161. Angstrom Sciences Main Business and Markets Served

Table 162. Angstrom Sciences Recent Developments/Updates

Table 163. Umicore Thin Film Products Sputtering Target Material for Semiconductor Corporation Information

Table 164. Umicore Thin Film Products Specification and Application



Table 165. Umicore Thin Film Products Sputtering Target Material for Semiconductor

Production (MT), Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 166. Umicore Thin Film Products Main Business and Markets Served

Table 167. Umicore Thin Film Products Recent Developments/Updates

Table 168. TANAKA Sputtering Target Material for Semiconductor Corporation Information

Table 169. TANAKA Specification and Application

Table 170. TANAKA Sputtering Target Material for Semiconductor Production (MT),

Value (US\$ Million), Price (USD/Kg) and Gross Margin (2018-2023)

Table 171. TANAKA Main Business and Markets Served

Table 172. TANAKA Recent Developments/Updates

Table 173. Key Raw Materials Lists

Table 174. Raw Materials Key Suppliers Lists

Table 175. Sputtering Target Material for Semiconductor Distributors List

Table 176. Sputtering Target Material for Semiconductor Customers List

Table 177. Sputtering Target Material for Semiconductor Market Trends

Table 178. Sputtering Target Material for Semiconductor Market Drivers

Table 179. Sputtering Target Material for Semiconductor Market Challenges

Table 180. Sputtering Target Material for Semiconductor Market Restraints

Table 181. Research Programs/Design for This Report

Table 182. Key Data Information from Secondary Sources

Table 183. Key Data Information from Primary Sources



List Of Figures

LIST OF FIGURES

Figure 1. Product Picture of Sputtering Target Material for Semiconductor

Figure 2. Global Sputtering Target Material for Semiconductor Market Value by Type, (US\$ Million) & (2022 VS 2029)

Figure 3. Global Sputtering Target Material for Semiconductor Market Share by Type: 2022 VS 2029

Figure 4. Metal Sputtering Target Material Product Picture

Figure 5. Alloy Sputtering Target Material Product Picture

Figure 6. Global Sputtering Target Material for Semiconductor Market Value by Application, (US\$ Million) & (2022 VS 2029)

Figure 7. Global Sputtering Target Material for Semiconductor Market Share by Application: 2022 VS 2029

Figure 8. Analog IC

Figure 9. Digital IC

Figure 10. Analog/Digital IC

Figure 11. Global Sputtering Target Material for Semiconductor Production Value (US\$ Million), 2018 VS 2022 VS 2029

Figure 12. Global Sputtering Target Material for Semiconductor Production Value (US\$ Million) & (2018-2029)

Figure 13. Global Sputtering Target Material for Semiconductor Production Capacity (MT) & (2018-2029)

Figure 14. Global Sputtering Target Material for Semiconductor Production (MT) & (2018-2029)

Figure 15. Global Sputtering Target Material for Semiconductor Average Price (USD/Kg) & (2018-2029)

Figure 16. Sputtering Target Material for Semiconductor Report Years Considered

Figure 17. Sputtering Target Material for Semiconductor Production Share by Manufacturers in 2022

Figure 18. Sputtering Target Material for Semiconductor Market Share by Company Type (Tier 1, Tier 2, and Tier 3): 2018 VS 2022

Figure 19. The Global 5 and 10 Largest Players: Market Share by Sputtering Target Material for Semiconductor Revenue in 2022

Figure 20. Global Sputtering Target Material for Semiconductor Production Value by Region: 2018 VS 2022 VS 2029 (US\$ Million)

Figure 21. Global Sputtering Target Material for Semiconductor Production Value Market Share by Region: 2018 VS 2022 VS 2029



- Figure 22. Global Sputtering Target Material for Semiconductor Production Comparison by Region: 2018 VS 2022 VS 2029 (MT)
- Figure 23. Global Sputtering Target Material for Semiconductor Production Market Share by Region: 2018 VS 2022 VS 2029
- Figure 24. North America Sputtering Target Material for Semiconductor Production Value (US\$ Million) Growth Rate (2018-2029)
- Figure 25. Europe Sputtering Target Material for Semiconductor Production Value (US\$ Million) Growth Rate (2018-2029)
- Figure 26. China Sputtering Target Material for Semiconductor Production Value (US\$ Million) Growth Rate (2018-2029)
- Figure 27. Japan Sputtering Target Material for Semiconductor Production Value (US\$ Million) Growth Rate (2018-2029)
- Figure 28. Global Sputtering Target Material for Semiconductor Consumption by Region: 2018 VS 2022 VS 2029 (MT)
- Figure 29. Global Sputtering Target Material for Semiconductor Consumption Market Share by Region: 2018 VS 2022 VS 2029
- Figure 30. North America Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)
- Figure 31. North America Sputtering Target Material for Semiconductor Consumption Market Share by Country (2018-2029)
- Figure 32. Canada Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)
- Figure 33. U.S. Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)
- Figure 34. Europe Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)
- Figure 35. Europe Sputtering Target Material for Semiconductor Consumption Market Share by Country (2018-2029)
- Figure 36. Germany Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)
- Figure 37. France Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)
- Figure 38. U.K. Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)
- Figure 39. Italy Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)
- Figure 40. Russia Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)
- Figure 41. Asia Pacific Sputtering Target Material for Semiconductor Consumption and



Growth Rate (2018-2023) & (MT)

Figure 42. Asia Pacific Sputtering Target Material for Semiconductor Consumption Market Share by Regions (2018-2029)

Figure 43. China Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)

Figure 44. Japan Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)

Figure 45. South Korea Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)

Figure 46. China Taiwan Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)

Figure 47. Southeast Asia Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)

Figure 48. India Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)

Figure 49. Latin America, Middle East & Africa Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)

Figure 50. Latin America, Middle East & Africa Sputtering Target Material for Semiconductor Consumption Market Share by Country (2018-2029)

Figure 51. Mexico Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)

Figure 52. Brazil Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)

Figure 53. Turkey Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)

Figure 54. GCC Countries Sputtering Target Material for Semiconductor Consumption and Growth Rate (2018-2023) & (MT)

Figure 55. Global Production Market Share of Sputtering Target Material for Semiconductor by Type (2018-2029)

Figure 56. Global Production Value Market Share of Sputtering Target Material for Semiconductor by Type (2018-2029)

Figure 57. Global Sputtering Target Material for Semiconductor Price (USD/Kg) by Type (2018-2029)

Figure 58. Global Production Market Share of Sputtering Target Material for Semiconductor by Application (2018-2029)

Figure 59. Global Production Value Market Share of Sputtering Target Material for Semiconductor by Application (2018-2029)

Figure 60. Global Sputtering Target Material for Semiconductor Price (USD/Kg) by Application (2018-2029)



- Figure 61. Sputtering Target Material for Semiconductor Value Chain
- Figure 62. Sputtering Target Material for Semiconductor Production Process
- Figure 63. Channels of Distribution (Direct Vs Distribution)
- Figure 64. Distributors Profiles
- Figure 65. Bottom-up and Top-down Approaches for This Report
- Figure 66. Data Triangulation



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